

UNITED STATES PATENT AND TRADEMARK OFFICE

UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria, Virginia 22313-1450 www.uspto.gov

APPLICATION N	0.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/611,978	•	07/03/2003	Hideo Fujiwara	239658US23X	4244
22850	7590	07/26/2006		EXA	MINER
C. IRVIN			CHEN, TIANJIE		
OBLON, SPIVAK, MCCLELLAND, MAIER & NEUSTADT, P.C. 1940 DUKE STREET				ART UNIT	PAPER NUMBER
ALEXAN	ALEXANDRIA, VA 22314			2627	

DATE MAILED: 07/26/2006

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)				
	10/611,978	FUJIWARA ET AL.				
Office Action Summary	Examiner	Art Unit				
	Tianjie Chen	2627				
The MAILING DATE of this communication ap Period for Reply	pears on the cover sheet with the c	orrespondence address				
A SHORTENED STATUTORY PERIOD FOR REPL WHICHEVER IS LONGER, FROM THE MAILING D. - Extensions of time may be available under the provisions of 37 CFR 1. after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory period Failure to reply within the set or extended period for reply will, by statut Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	DATE OF THIS COMMUNICATION 136(a). In no event, however, may a reply be tin will apply and will expire SIX (6) MONTHS from the, cause the application to become ABANDONE	N. nely filed the mailing date of this communication. D (35 U.S.C. § 133).				
Status						
 Responsive to communication(s) filed on 16 M This action is FINAL. Since this application is in condition for allowed closed in accordance with the practice under the second second	s action is non-final. ance except for formal matters, pro					
Disposition of Claims						
4) ☐ Claim(s) 1-21,23,24 and 26-39 is/are pending 4a) Of the above claim(s) 9-12 and 30-38 is/ar 5) ☐ Claim(s) is/are allowed. 6) ☐ Claim(s) 1-8,13-21,23,24,26-29 and 39 is/are 7) ☐ Claim(s) is/are objected to. 8) ☐ Claim(s) are subject to restriction and/or Application Papers	re withdrawn from consideration.					
9) The specification is objected to by the Examine 10) The drawing(s) filed on is/are: a) accomposed and applicant may not request that any objection to the Replacement drawing sheet(s) including the correct of the specific part of t	cepted or b) objected to by the lead rawing(s) be held in abeyance. See ction is required if the drawing(s) is object.	e 37 CFR 1.85(a). jected to. See 37 CFR 1.121(d).				
Priority under 35 U.S.C. § 119						
 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. 						
Attachment(s) 1) Notice of References Cited (PTO-892)	4) 🔲 Interview Summary	(PTO-413)				
 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08 Paper No(s)/Mail Date 	Paper No(s)/Mail Da					

Art Unit: 2627

Final Rejection

Election/Restrictions

1. Newly submitted claim 1 directed to an invention that is independent or distinct from the invention originally claimed for the following reasons: the newly submitted claim 1 recites "wherein each of said at least two CC layer structures is located on a different side of the thin non-magnetic spacer layer;" the elected species III drawn from Fig. 9 does not possess this feature. Since claim 1 recites a thin non-magnetic spacer layer and at least two current-confining (CC) layer structures. In Fig. 9, there are only two layers 94 and 94' can be considered as the thin non-magnetic spacer layer and CC layer structures. Therefore, at least one layer from 94 and 94' should be considered as the thin non-magnetic spacer layer as well as one of the CC layer structures. It shows it is impossible to have the feature of "wherein each of said at least two CC layer structures is located on a different side of the thin non-magnetic spacer layer." This feature may direct to the species drawn from Fig. 7, which is non-elected.

Since applicant has received an action on the merits for the originally presented invention, this invention has been constructively elected by original presentation for prosecution on the merits. Accordingly, newly submitted claim 1 withdrawn from consideration as being directed to a non-elected invention. See 37 CFR 1.142(b) and MPEP § 821.03. And only the previously presented non-amended claim 1 will be admitted on record.

Claim Rejections - 35 USC § 112

The following is a quotation of the first paragraph of 35 U.S.C. 112:

The specification shall contain a written description of the invention, and of the manner and process of making and using it, in such full, clear, concise, and exact terms as to enable any person skilled in the art to which it pertains, or with which it is most

nearly connected, to make and use the same and shall set forth the best mode contemplated by the inventor of carrying out his invention.

2. Claims 1-8, 13-18, and 39 are rejected under 35 U.S.C. 112, first paragraph, as failing to comply with the enablement requirement. The claim(s) contains subject matter, which was not described in the specification in such a way as to enable one skilled in the art to which it pertains, or with which it is most nearly connected, to make and/or use the invention.

As described above, the elected Species III drawn from Fig. 9 does not possess the feature: "wherein each of said at least two CC layer structures is located on a different side of the thin non-magnetic spacer layer." One skilled in the art to which it pertains, or with which it is most nearly connected, cannot make and/or use the invention.

Other claims are rejected for their dependence from independent claim 1.

Following rules set in MPEP, the following rejection will still be done for the non-admitted amended claim 1.

Claim Rejections - 35 USC § 102

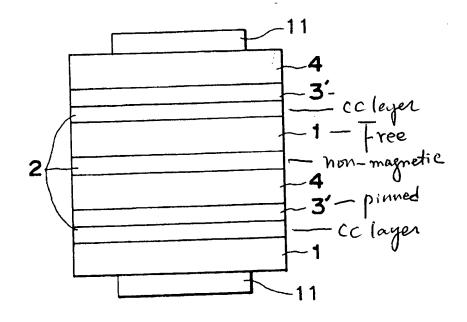
The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.
- 3. Claims 1-8 and 39 are rejected under 35 U.S.C. 102(e) as being anticipated by Sakakima et al (US 5,715,121).

Application/Control Number: 10/611,978

Art Unit: 2627



Claim 1, Sakakima et al shows a CPP spin-valve element with two electrodes 11 and 11 (Column 3, line 20) formed on an inherent substrate (See Fig. 5 attached above and column 5, lines 4 – 49) including: a free layer structure including at least one ferromagnetic layer; a pinned layer structure including at least one ferromagnetic layer, the free layer is magnetically softer than the pinned layer (column 4, lines 376-39); a thin non-magnetic spacer layer structure configured to separate the free layer and the pinned layer to prevent a magnetic coupling between the free and pinned layer structures, and to allow an electric current to go there through; and wherein at least two current-confining (CC) layer structures 2 including at least two parts 21 and 22 having significantly different current conductivities (Fig. 2A and 2B, column 3, lines

Art Unit: 2627

44-46); wherein each of the at least two CC layer structures is located on a different side of the thin non-magnetic spacer layer.

Claim 2, Sakakima et al further shows that the pinned layer structure comprises a ferromagnetic layer 3' exchange coupled with an antiferromagnetic layer 4 (Column 5, lines 34-42).

Claim 3, Sakakima et al shows in Fig. 2A that the CC-layer structure includes a mosaic structure of conducting and insulating parts (Column 3, lines 44-46).

Claims 4 and 6, Sakakima et al further shows that the mosaic structure includes metal and oxide (Column 4, lines 8-20).

Claims 5 and 7, Sakakima et al shows that the metal is Cu, the oxide is an oxides of A1 (Column 4, lines 8-20).

Claim 8, Sakakima et al further shows in Fig. 5 attached above that one of the CC-layer structures is located in the vicinity of the free layer structure, and another of the CC-layer structures is located in the vicinity of the pinned layer structure.

Claim 39, Sakakima et al shows the CC-layer structures are fabricated.

A "product by process" claim is directed to the product per se, no matter how actually made, see In re Hirao, 190 USPQ 15 at 17 (footnote 3 CCPC, 5/27/76); In re Brown, 173 USPQ 685 (CCPA 5/18/72); In re Luck, 177 USPQ 523 (CCPA, 4/26/73); In re Fessmann, 180 USPQ 324 (CCPA, 1/10/74); In re Thorpe, 227 USPQ 964 (CAFC, 11/21/85). The patentability of the final product in a "product by process" claim must be determined by the product itself and not the actual process and an old or obvious product produced by a new method is not patentable as a product, whether claimed in "product by process" claims or not. In instant case, "with a lithography technique

Application/Control Number: 10/611,978

Art Unit: 2627

using a focused ion beam or an electrochemical scanning probe" is a process related limitation, which gains no weight in determining patentability.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

- (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 4. Claims 13, 15, 19, 21, 23, and 28 are rejected under 35 U.S.C. 103(a) as being unpatentable over Sakakima et al in view of Carey et al (US 6,686,068).

Claims 13 and 19 Carey et al shows that the width of the confined current paths of the CC-layer structures is about $2^{1/2}$ times the width of the layer (Since the conductor has volume percentage of 60%, column 5, line 22-24), the width of the layer is 50nm (Column 5, lines 50-54). The confined current paths of the CC-layer structures is about $(0.6)^{1/2}$ X 50 nm =39nm. Sakakima shows that the thickness of the free layer is t=10 nm (Column 7, lines 47-48) and $t^{3/2}$ =31.7 nm. It shows that the width of the confined current paths of the CC-layer structures is greater than $t^{3/2}$.

Claim 15, Carey et al shows that at least one confined-current path is formed within every flux path of a width of an exchange length of the free layer except at side edge of the free layer since both application and reference have same structure.

Claim 19, as described above, Carey et al shows a CPP spin-valve element formed on a substrate including: a free layer structure including at least one ferromagnetic layer; a pinned layer structure including at least one ferromagnetic layer, the free layer is magnetically softer than the pinned layer; and a thin non-magnetic current confining

Art Unit: 2627

CC-layer structure configured to separate the free and pinned layers, to prevent a substantial magnetic coupling between the free and pinned layer structures, and to allow an electric current to go through the confined current paths; wherein the width of the confined current paths of the CC-layer structure is about 35nm.

Claim 23, as described above, the width of the confined current paths of said first and second CC-layer structures is greater than $t^{3/2}$, where t is the thickness of at measured in nanometers.

Claim 28, as described above, Sakakima et al and Carey et al shows a CPP spin-valve element formed on a substrate including: a free layer structure including at least one ferromagnetic layer; and a pinned layer structure including at least one ferromagnetic layer, the free layer is magnetically softer than the pinned layer; wherein at least one CC-layer structure incorporated therein, which is configured to separate the free and pinned layers and to allow an electric current to go through the confined current paths, the width of the confined current paths of said first and second CC-layer structures is greater than t^{3/2}, where t is the thickness of at measured in nanometers.

Claim 21, as described above, Sakakima et al and Carey et al show a CPP spinvalve element formed on a substrate including: a free layer structure including at least
one ferromagnetic layer; a pinned layer structure including at least one ferromagnetic
layer, the free layer is magnetically softer than the pinned layer; and a first thin nonmagnetic current confining (CC)-layer structure configured to separate the free and
pinned layers, to prevent a substantial magnetic coupling between the free and pinned
layer structures, and to allow an electric current to go through the confined current
paths; wherein a second CC-layer structure placed across at least one of the free layer

Application/Control Number: 10/611,978

Art Unit: 2627

and the pinned layer; wherein conducting parts of said CC-lavers are located in a cascade manner (Figs 2A and 2B) and at least an inner edge to edge distance of a projection of the conducting parts of the CC-lavers forming at least one of the current paths through said free layer structure or said pinned layer onto the layer plane, which is 39nm, is made greater than the thickness of at least one of said free layer structure, which is 10 nm.

5. Claims 16 is rejected under 35 U.S.C. 103(a) as being unpatentable over Sakakima et al in view of AAPA (Applicant Admitted Prior Art).

Claim 16; AAPA shows in P. 18 "a pair of CC-layer structures are located on both sides across the free layer structure or the pinned layer whose conducting parts are located in a cascade manner, and at least the inner edge to edge distance of a projection of the conducting parts of the CC-layers forming at least one of the current paths through at least one of the free layer structure and the pinned layer onto the layer plane is made greater than the thickness of at least one of the free layer structure and the pinned layer;" and it would provide high magnetoresistance ΔR .

One of ordinary skill in the art would have been motivated to apply this relation into Sakakima et al's device for obtaining high magnetoresistance ΔR .

6. Claims 14, 20, 24 and 29 are rejected under 35 U.S.C. 103(a) as being unpatentable over Sakakima et al in view of Carey et al as applied to claim 21 above, and further in view of Kamijo (US 6,819,532).

Claims 14, 20, 24 and 29, Sakakima et al shows that the thickness of the free layer is 10 nm as described above and Sakakima et al further shows that various

Application/Control Number: 10/611,978 Page 9

Art Unit: 2627

changes and modification are apparent to those skilled in the art. Such changes and modifications are to be understood as included within the scope of the present invention (Column 8, lines 24-27). Kamijo shows a magnetic head wherein the thickness if the free layer is to be in the range of 1-10 nm (Column 19, lines 1-2). One of ordinary skill in the art would have been motivated to include this thickness range of free layer as the scope of Sakakima et al's device. If take t=5 nm, then the width of the confined current paths of said first and second CC-layer structures is greater than two times of $t^{3/2}$, where t is the thickness of at measured in nanometers.

7. Claims 17, 18 are rejected under 35 U.S.C. 103(a) as being unpatentable over Sakakima et al in view of AAPA (Applicant Admitted Prior Art).

Claims 26 and 27 are rejected under 35 U.S.C. 103(a) as being unpatentable over Sakakima et al and Carey et al in view of AAPA (Applicant Admitted Prior Art).

Claim 17, 18, 26, and 27; AAPA shows in Applicant's Specification p. 17 the length of at least one of the current paths through at least one of the free layer structure and the pinned layer structure is greater than the spin diffusion length in at least one of the free layer structure and the pinned layer structure and is smaller than 3/or 2 times as large as the spin diffusion length of the current paths. Since AAPA show it is an optimized number, one of ordinary skill in the art would have been motivated to apply this relation into Carey et al's for optimizing the performance of the device.

Response to Arguments

8. Applicant's arguments with respect to claims have been considered but are moot in view of the new ground(s) of rejection.

• Applicant argues that Applicant has recited some feature in P. 18. However, Applicant has recited the feature at the first place in PP. 17 and 18 as from published reference. Therefore, the features recited are recognized as prior art.

Page 10

Conclusion

9. Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, THIS ACTION IS MADE FINAL. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Tianjie Chen whose telephone number is 571-272-7570. The examiner can normally be reached on 8:00-4:30, Mon-Fri.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Hoa Nguyen can be reached on 571-272-7579. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Application/Control Number: 10/611,978 Page 11

Art Unit: 2627

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

TIAMJIE CHEN PRIMARY EXAMINE